# IIN-AS

Institut luxembourgeois de la normalisation de l'accréditation, de la sécurité et qualité des produits et services

## ILNAS-EN 50527-2-3:2021

## Procedure for the assessment of the exposure to electromagnetic fields of workers bearing active implantable medical devices - Part 2-3: Specific

Procédure pour l'évaluation de l'exposition des travailleurs porteurs de dispositifs médicaux implantables actifs aux champs électromagnétiques - Partie

Verfahren zur Beurteilung der Exposition von Arbeitnehmern mit aktiven implantierbaren medizinischen Geräten gegenüber elektromagnetischen Feldern

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# EUROPEAN STANDARD LINAS-EN 50527-2-3:202 EN 50527-2-3

# NORME EUROPÉENNE

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**English Version** 

## Procedure for the assessment of the exposure to electromagnetic fields of workers bearing active implantable medical devices - Part 2-3: Specific assessment for workers with implantable neurostimulators

Procédure pour l'évaluation de l'exposition des travailleurs porteurs de dispositifs médicaux implantables actifs aux champs électromagnétiques - Partie 2-3 : Evaluation spécifique aux travailleurs porteurs de neurostimulateurs implantés Verfahren zur Beurteilung der Exposition von Arbeitnehmern mit aktiven implantierbaren medizinischen Geräten gegenüber elektromagnetischen Feldern - Teil 2-3: Besondere Beurteilung für Arbeitnehmer mit implantierbaren Neurostimulatoren

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